Supplementary Information

Electrodeposited CuSbTe Thin Films with Enhanced Thermoelectric Performance

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Figure S1. EDX spectra of (a) Sb_2Te_3 , (b) Cu0.2SbTe, (c) Cu0.4SbTe, (d) Cu0.6SbTe, (e) Cu0.8SbTe, (f) Cu1.0SbTe.

Bath	Average Film	Cu (at%)	Sb (at%)	Te (at%)
	thickness (µm)			
		0	36.95	63.05
		0	37.20	62.80
Sb ₂ Te ₃	8.99	0	36.95	63.05
		0	36.84	63.16
		0	36.23	63.77
		0	36.83	63.17
		3.05	34.86	62.09
		2.71	35.23	62.06
Cu0.2SbTe	5.80	2.75	35.28	61.96
		2.84	35.06	62.10
		2.91	35.05	62.03
		2.85	35.10	62.05
		5.65	33.82	60.53
		5.62	33.69	60.69
Cu0.4SbTe	5.49	5.85	33.55	60.60
		5.76	33.73	60.51
		5.56	33.81	60.63
		5.69	33.72	60.59
		10.34	30.68	58.98
		9.49	31.48	59.02
Cu0.6SbTe	4.86	9.84	30.92	59.24
		10.38	31.31	58.31
		10.27	30.52	59.21
		10.06	30.98	58.96
		11.76	30.66	57.58
		11.31	30.60	58.08
Cu0.8SbTe	4.56	11.32	30.54	58.14
		11.70	30.34	57.96
		11.86	30.34	57.80
		11.59	30.50	57.91
		15.27	28.79	55.94
		15.32	28.49	56.18
Cu1.0SbTe	4.35	15.63	28.59	55.78
		15.34	28.41	56.25
		15.93	28.07	56.00
		15.50	28.47	56.03

Table S1. The average film thickness and elemental composition of Sb_2Te_3 and CuSbTe films.



Figure S2. (a) HRTEM image Cu0.4SbTe film showing crystalline and amorphous region, (b) Distribution of amorphous and crystalline fraction of CuSbTe, (c) Dislocation in CuSbTe film, (d and e) Amorphous-crystalline features with dislocations at grain boundaries (f) SAED pattern of Cu0.4SbTe in spotted region of the inset.



Figure S3. XPS survey spectra of pure Sb_2Te_3 and CuSbTe films.



Figure S4. The core level XPS signals of (a) Sb 3d, (b) Cu2p, (c) and Te 3d for Cu0.4SbTe film for different etching time.